

<b>PATENT</b>	
<b>IN THE UNITED STATES PATENT AND TRADEMARK OFFICE</b>	
In re Application of: Thomas Werner Hartmut Ruelke Christof Streck  Serial No.: 10/691,274  Filed: 10/22/2003	Examiner: Daborah Chacko Davis  Group Art Unit: 1756  Att'y Docket: 2000.105300  Confirmation No.: 4933
For: TECHNIQUE FOR REDUCING RESIST POISONING IN FORMING A METALLIZATION LAYER INCLUDING A LOW-K DIELECTRIC	Customer No. 023720

**RESPONSE TO OFFICE ACTION DATED JUNE 21, 2006**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

This paper is submitted in response to the Office Action dated June 21, 2006, for which the three-month date for response is September 21, 2006.

It is believed that no fee is due; however, should any fees under 37 C.F.R. §§ 1.16 to 1.21 be required for any reason, the Commissioner is authorized to deduct said fees from Williams, Morgan & Amerson, P.C. Deposit Account No. 50 0786/2000.105300.

Reconsideration of the application is respectfully requested.